

L Number	Hits	Search Text	DB	Time stamp
1	651	plasma with anneal	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/20 09:29
8	6	(plasma with anneal)and (ALD or atomic near layer near deposition)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/20 09:31